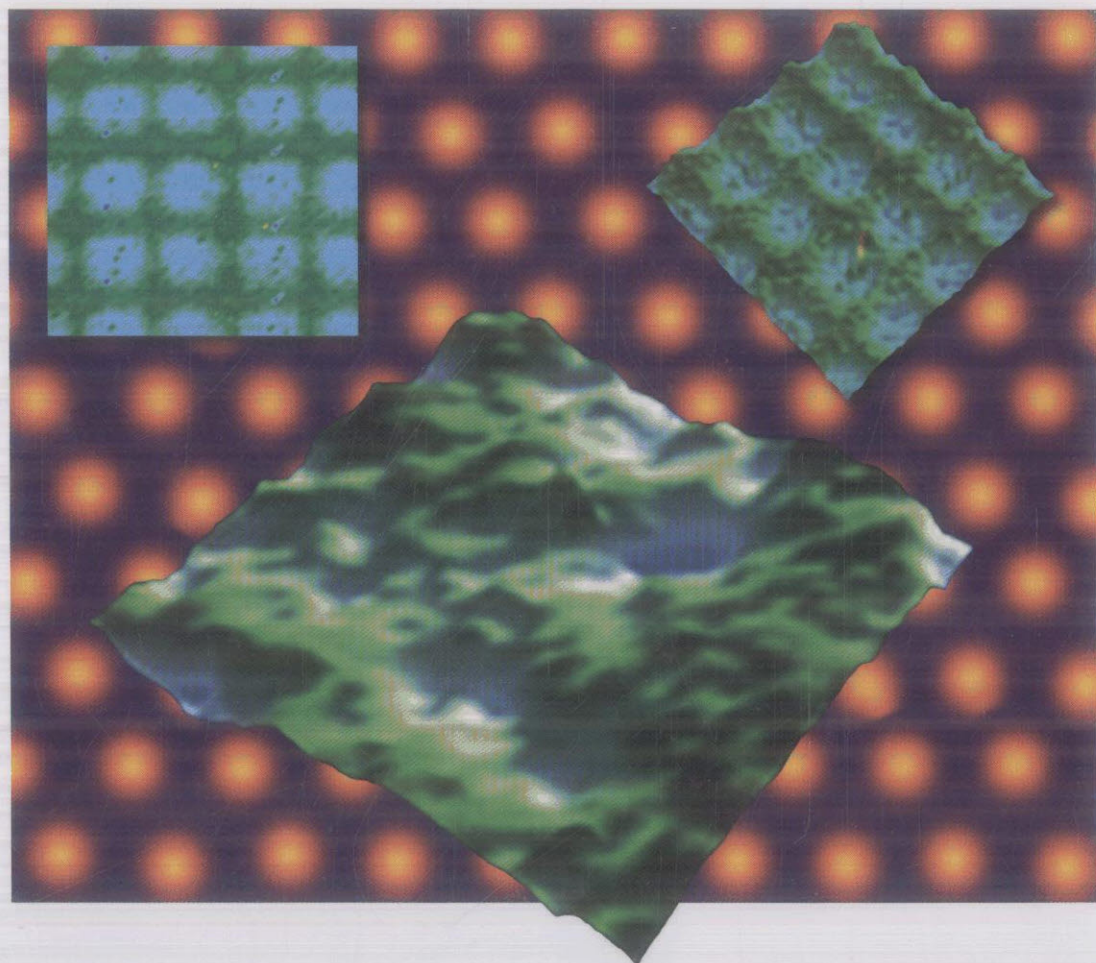


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Functional Polymer Films

Volume 1:
Preparation and Patterning



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